



# THIN FILM DEPOSITION SYSTEMS

A VACUUM SCIENCE & TECHNOLOGY COMPANY

# THE COMPANY



Hind High Vacuum (HHV) is India's premier thin film and vacuum technology company. With over 55 years of expertise in the design and manufacture of high vacuum equipments and thin film components for research and industrial applications. HHV's products are integral to multiple strategic, academic and commercial sectors. HHV has multiple manufacturing centres located in and around Bengaluru, India.

The Thin Film Equipment Division manufactures a wide range of PVD and CVD coating systems for research and industrial purposes. The Thin Films and Optics Division designs and fabricates thin film coatings for optical, functional and decorative applications. The Thermal Systems Division specializes in building vacuum furnaces, hot presses and special purpose vacuum equipment for complex metallurgical applications.

HHV is a leading exporter for coating equipment with branches in the United Kingdom and distributors worldwide. HHV is an ISO 9001: 2015, ISO 45001: 2018, EMS 14001: 2015, certified company.

# History



1965

Hind High Vacuum founded as a small-scale industry in Bangalore, India



1967

Developed India's first indigenous 12" lab model vacuum coating unit in association with the Indian Institute of Science



1991

Established the thin films division and began producing optical filters



2002

Built and supplied the largest vertical coating system for 2.2m diameter telescope mirror coatings at an elevation of 14800 ft. above sea level at Hanley, Ladakh



2005

Developed a robot- controlled sputter coating system for conductive and transparent coating on aircraft canopy and windshield with process technology



2007

Established the 6.5 acre plant in Dabaspet, Bangalore, India which includes international contract manufacturing operations for Edwards' range of thin film deposition equipment and diffusion pumps



2008

Installed the horton spheres coupled with hyersonic wind tunnel at Trivandrum, India: The spheres are 16.13 m in diameter (equivalent to the height of a five storeyed building), with a vacuum system having a pumping speed of 1,20,000 m<sup>3</sup>/hr



2009

HHV's international activity commences with the export of thin film deposition equipment: Acquired the Edwards thin films lineage and established HHV Ltd. in United Kingdom



2010

Developed a complete turnkey line for the production of amorphous silicon solar panels with a capacity of 10MW per annum



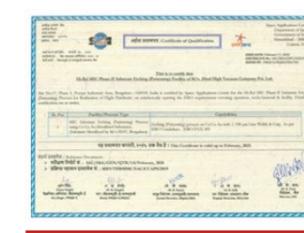
2011

Commissioned a robotized TIG welding system with man entry and external robot teaching facility for welding aircraft engine components in high purity inert gas environments



2017

Established the thin films and optics facility to fabricate high precision optical components in the visible and infrared spectrum



2020

Received space qualifications for lithography of HMC substrates

# Research & Development

HHV has an R&D team that works on machine design, hardware and process recipes. The team of scientists and engineers continually advance the company's technology base by upgrading its products and processes through extensive research and testing.

The R&D group collaborates with various academic and research institutes across the country to upscale and commercialize technologies developed out of research labs.

Our R&D facility is recognized by the Department of Scientific and Industrial Research (DSIR), Govt. of India.

HHV has an annual internship program that receives applicants from India's leading institutions. Selected candidates go through a 6 week internship consisting of two weeks of class room lessons and 4 weeks of project work.



# Awards & Recognition

HHV received a National Award for successful commercialization of indigenous technology in 2018 from the President of India



HHV has received the 'Star performer' Award from EEPC for 5 years in a row



HHV was awarded the 'Technovation Award 2011' from the Indian Semiconductor Association (ISA) for the indigenous development of an amorphous silicon production line



# Manufacturing Capabilities

HHV constantly upgrades its manufacturing capabilities to keep in line with the evolving demands of the market.

This includes all aspects of the manufacturing process:

- Engineering design
- Process automation
- Precision machining and fabrication
- Electropolishing
- TIG welding
- Vacuum brazing
- Global supply chain
- Electro-mechanical assembly
- Comprehensive product testing

HHV's Thin Films and Optics division is a leading manufacturer of high precision optical components and thin film coatings. It is equipped with ISO 7, ISO 8 clean rooms and class 100 laminar flow stations.

This division manufactures dichroic coated optics, laser filters, narrow band interference filters, hybrid micro circuits, periscope prisms, thin film heaters and infrared optics for a variety of applications in industrial, space and defence technologies.

HHV's precision Optics Fabrication Lab (OFL) is equipped with state of the art technology for single point diamond turning (SPDT) along with slitting, trepanning, curve generation, grinding, polishing, centering and edging for high precision spherical and aspherical optics for the visible and infrared light ranges. This is the country's largest flat optics fabrication facility in the private sector.

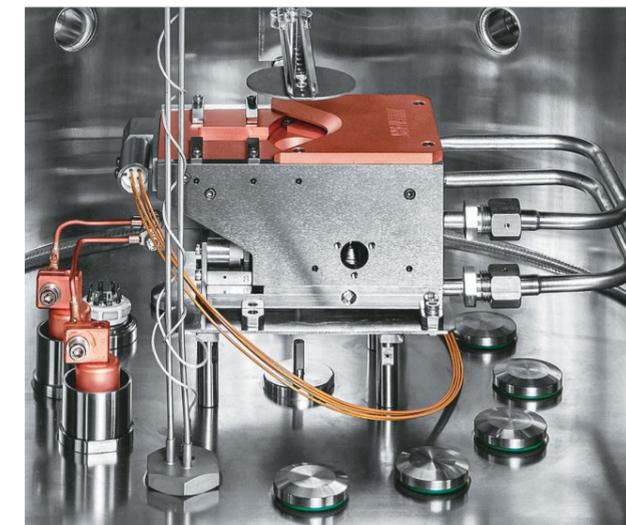


# PROCESS TECHNOLOGY

## ELECTRON BEAM EVAPORATION

A stream of high energy electrons heats up the source to generate vapours which condense onto the substrate to form a thin film.

HHV provides electron beam guns from a single to large capacity-multi pocket sources enabling complex multi-layer depositions requiring higher film thicknesses.



## MAGNETRON SPUTTERING

Magnetron sputtering employs plasma to generate ions which bombard the surface of a 'target' which then sputters the thin film material on to a substrate.

HHV offers a range of circular and linear magnetron sputter sources, engineered to meet R&D and production requirements.



## PECVD

Plasma enhanced chemical vapor deposition (PECVD) processes induce a chemical reaction between powered electrodes which results in a thin film being deposited on a substrate.

HHV offers PECVD systems in various configurations such as single chamber, load-lock coupled and multi-chamber cluster tool to suit customer needs.



## THERMAL EVAPORATION

Thermal evaporation involves heating a material inside a high vacuum chamber until it boils or sublimates, and then condenses on a substrate to form a thin film.

HHV has been developing deposition systems with various types of crucibles and multi-turret/multi-deposition sources customized to user needs.

## EFFUSION CELLS

Effusion cells are specialized thermal evaporation sources offering precise temperature control for the deposition of sensitive materials.

HHV has been developing deposition systems for organic materials for use in OLED displays, solar cells, and flexible electronic devices.

HHV develops specialised evaporation systems for continuous wire feed and fast cycle production.

## ION BEAM SPUTTERING

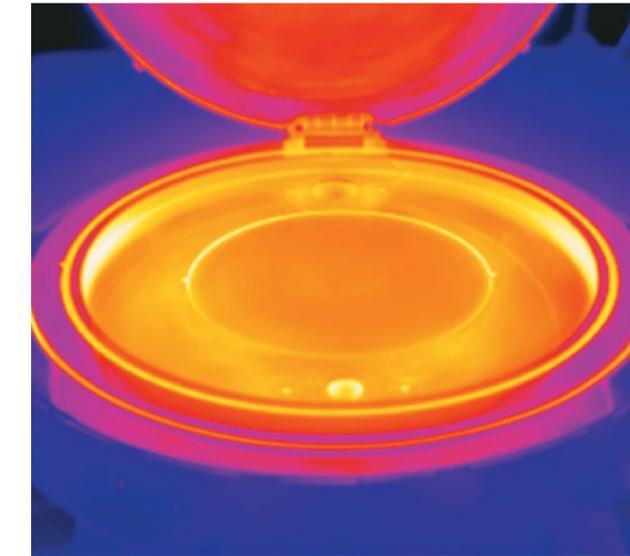
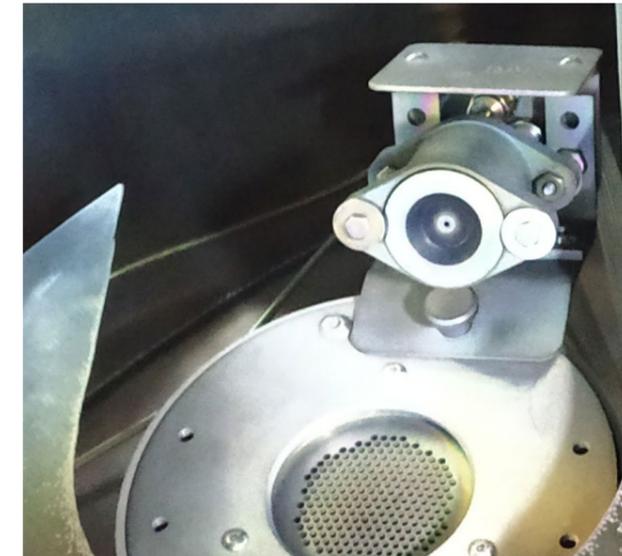
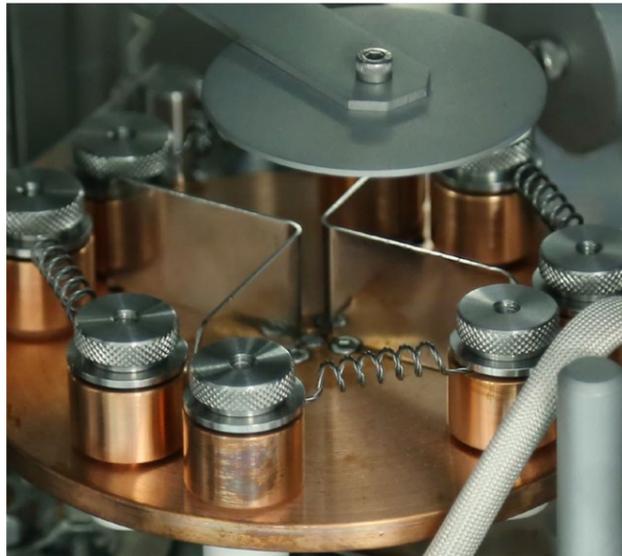
Ion beam sources convert a process gas into an output ion beam that is parallel or divergent to the target. Parallel beams are used to sputter material with high-energy ions, and divergent beams are used on large-area work holders with lower energy ions during the deposition process.

HHV applies ion beam technology for research and production systems.

## ATOMIC LAYER DEPOSITION

Atomic layer deposition (ALD) is a thin-film deposition technique based on the sequential use of precursors and gives 100 percent conformal coverage and excellent thickness uniformity with pinhole free coatings.

HHV offers highly cost effective thermal ALD tools with built-in process recipes and a user-friendly software interface.



# WORK HOLDERS

HHV manufactures a range of work holders which are designed to suit a variety of PVD and PECVD processes.

The work holders have many standard functionalities such as rotation, heating, and electrical biasing(RF/DC) to improve adhesion, uniformity and to control film density.

HHV also offers custom solution for substrate holders based on the sample size, geometry, throughput requirement and temperature range.

## ROTATION

HHV provides various options such as rotary, planar planetary, Knudsen planetary, glancing angle deposition (GLAD), and substrate flip mechanism. Substrate rotation can also be supplemented by source masking to ensure uniform depositions.

## BIASING

Substrate holders can be provided with various biasing options such as DC, pulsed DC, and at alternating frequencies such as MF, RF and mixed RF and LF frequencies.

## HEATING

Substrate heating solutions can be provided for a wide range of temperatures up to 800 degrees. A range of options such as Nichrome, enclosed tubular heaters, IR Lamps, Pyrolytic Graphite, and PBN can be used. Closed loop PID controllers and associated electronics ensure a highly stable temperature on the substrates throughout deposition.

## LINEAR Z-SHIFT

Linear Z-shift motion provides the option to change source to sample distance up to 150 mm. This feature is useful for determining the optimum deposition conditions and to facilitate substrate transfer between chambers.

## LOAD LOCK

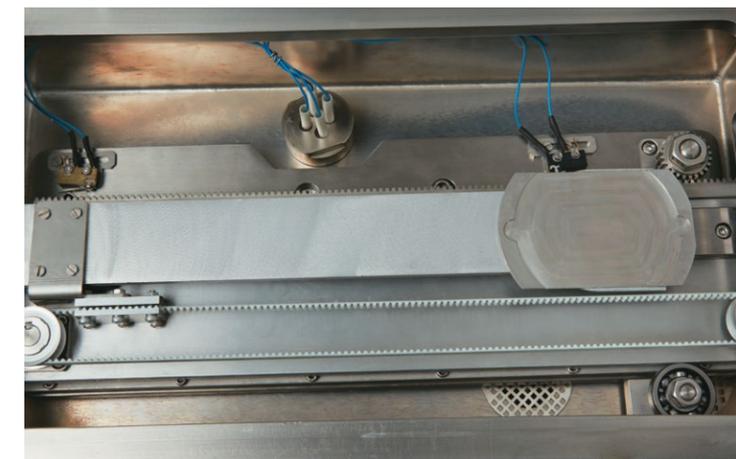
Load Locks allow samples to be transferred into the process chamber without venting the chamber enabling the user to reduce cycle times and potential sample contamination.

## TRANSFER

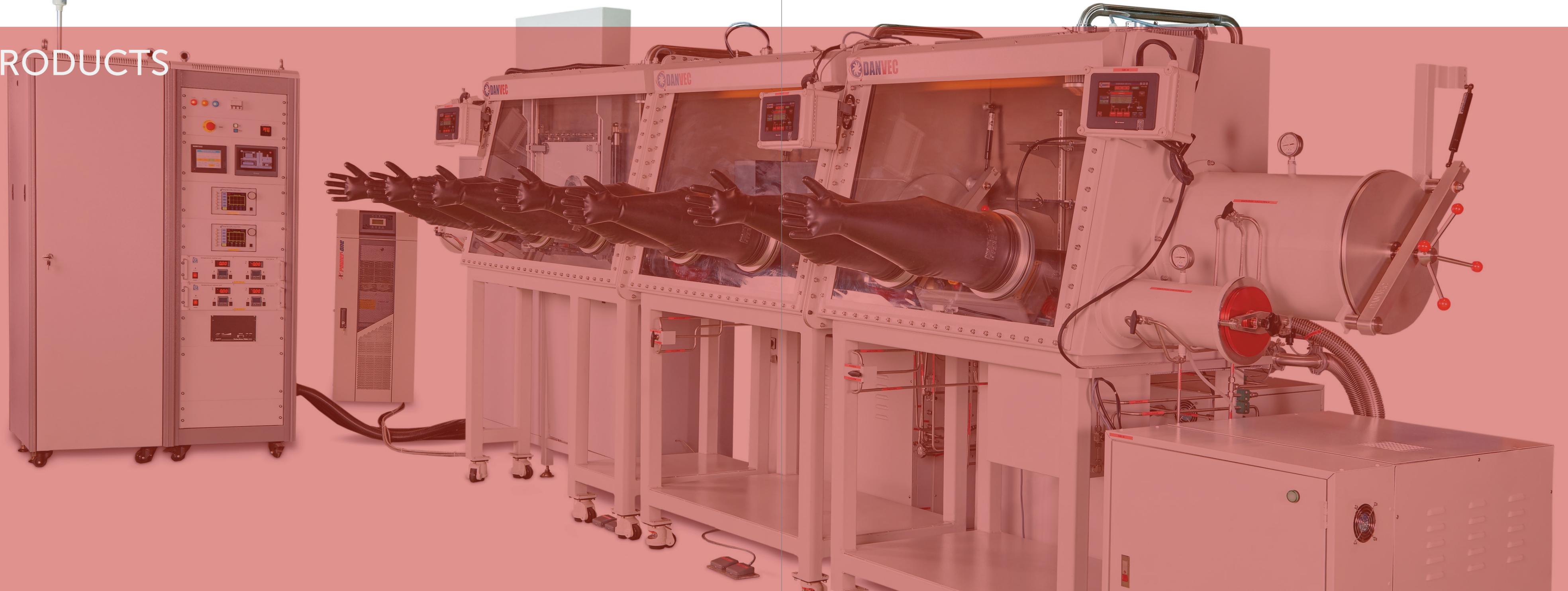
Linear transfers are available with manual or motorized actuation. A telescopic arm transports sample holders and samples between chambers or from the load lock chamber to main chamber.

## ROBOTICS

Specialized high vacuum compatible multi-axis robot with external teaching facility to map contours and uniformly coat complex components.



# PRODUCTS



# BENCH TOP (BT) SERIES

Our BT coaters are perfect to deposit conductive coatings for sample preparation for electron microscopy imaging. A fully automated user-interface provides single touch deposition capability from a range of pre-programmable recipes.

## FEATURES:

- Compact design for a minimized footprint
- Multiple accessory options for a number of surface preparation processes
- Complete process automation with a high resolution colour touch screen user interface
- Range of work holders
- 660 mm x 520 mm system footprint
- In-situ process monitoring option
- Turbo pump option



# SMART COAT 3.0

The Smart Coat 3.0 trio are ideal entry level solutions for budding researchers. The platform provides cost-effective solutions for a range of PVD processes using thermal resistance sources, glow discharge cleaning, electron beam sources, effusion cells, or magnetron sputtering sources.

## FEATURES:

- Variety of chamber options
- Supports multiple deposition process
- Range of work holders and heaters
- In-situ process monitoring and control option
- PLC controller for automated vacuum cycle
- 630mm x 1500 mm system footprint



# RIE

HHV's Reactive Ion Etching systems are used in micro and nanofabrication applications. RIE combines both physical sputtering, and chemical activity of the reacting species to ensure high etch anisotropy as well as greater material selectivity.

## FEATURES:

- Low cost of ownership
- Accommodates up to 6" diameter wafer sizes
- Optimized showerhead design for uniform gas distribution
- Adjustable source to shower head distance
- Water cooled substrate holder
- 4 to 8 MFC controlled gas lines
- Fluorine and Chlorine based chemistries offered
- Pre-programmed process recipes on select models



# ALD 150

Our fully-automated stand alone thermal atomic layer deposition (ALD) system can deposit pin-hole free films with extreme surface conformality. The system can accommodate wafer sizes of up to 6 inches in diameter and a gas manifold for up to six precursor lines.

## FEATURES:

- Fast pulse gas delivery valves with integrated purging
- Basic version with two precursor lines
- Extendable upto 6 precursor lines
- Comes with built-in recipes for  $\text{Al}_2\text{O}_3$ , ZnO and  $\text{TiO}_2$
- Complete process automation with LabVIEW interface
- 893 mm x 1377 mm system footprint
- Dry pump option
- Custom designed for your process needs



# AUTO SERIES

Our popular Auto series platform offers compact, economical and rugged solutions suitable for multiple process applications. Users can choose from a wide range of modular process accessories for numerous research applications.

## FEATURES:

- Variety of chamber options
- Supports multiple deposition processes
- Range of work holders and heaters
- In-situ process monitoring and vacuum control option
- Compatible with new or existing glove box units
- PLC controller for automated vacuum cycle
- No pneumatics, all electronic components
- CE standards
- 630mm x 1500 mm system footprint
- Custom designed for your process needs



# GBIC

HHV's glove box integrated coaters (GBIC) are designed for easy integration of vacuum coaters with glove boxes from most major manufacturers. This allows for handling, transferring and coating samples under controlled atmospheres for end-to-end processing.

## FEATURES:

- Ergonomic design for easy access from glove box
- Side-opening and vertically-opening front door options
- Convenient and interlocked service access via back side hinged door
- Wide range of process accessories
- In-situ mask change-over options
- Full integrated process control with recipe control software management
- Custom designed for your process requirements



# CLUSTER TOOL (CT) SERIES

The CT series combines multiple PVD and CVD process capabilities in the same run to fabricate multilayer stacks and complex device architectures. Each module can be configured individually to meet the user's technological requirements, while also being extendable for future expansion.

## FEATURES:

- Modular design with up to 5 process chambers
- Manual or automated substrate transfer
- Choice of system configurations
- Sample heating, cooling, bias, and cleaning options
- PC/PLC controlled recipes for single, batch, or automated processes
- Advanced data logging and process tracking
- Custom designed for your process needs



# SAARA SERIES

HHV's SAARA platform is made of superior performance single block aluminum chamber to process electronic and optical coatings of the highest quality. SAARA is the common platform between PECVD, RIE and plasma ALD tools and comes with a load-lock chamber, automated substrate transfer mechanism and a touch-screen PC with complete process automation.

## FEATURES:

- Compact cabinet design offering minimized footprint
- Accommodates up to 8" wafers
- Dual frequency (RF & LF) power supply for film stress control
- Substrate biasing options of DC or RF
- Built-in process recipes
- In-situ cleaning
- Substrate heating up to 800°C



## ATS 500

The ATS 500 is the latest model of mid sized coaters for production and large wafer R&D applications. The ATS 500 is clean room compatible and offers high throughput efficiency. A fully automated user-interface provides single touch deposition capability from a range of pre-programmable recipes.

### FEATURES:

- Modular segmentation of system components
- 500 mm wide x 500 mm high, D-shaped chamber with hinged door
- Extended height versions are available for applications such as lift-off coatings
- Supports multiple deposition process
- Full colour touch screen PLC with integrated recipe-driven process and vacuum control
- 1460mm x 1670 mm system footprint
- Custom designed for your process needs



## TF SERIES

The TF series is our most versatile platform with large chamber options that can accommodate any deposition source. This is a highly customizable platform suitable for a wide range of laboratory and industry applications.

### FEATURES:

- Wide range of chambers from  $\Phi$ 500 mm to 1400 mm
- Supports multiple deposition processes
- Available with load lock
- Compatible with new or existing glove box units
- Advance PC based software control
- Process data logging
- Optimized distribution-masks for high rates and uniformity
- Clean room compatibility
- Custom designed for your process needs



## Identicoat (ID) Series

HHV's identicoat series of coaters are designed for forensic laboratories. These systems utilise a Vacuum Metal Deposition (VMD) technique developed for the detection of finger marks on substrates such as plastic bags, sheeting, etc. that are difficult to handle using conventional techniques.

### FEATURES:

- Rugged and proven design
- Easy access vacuum pumping station
- Adjustable source positioning
- Completely automated process cycle
- Easy loading sample hood
- Remote access for support and trouble shooting
- Fully interlocked for operator and machine safety



## Twin Door Metallizer

HHV is a leading supplier of state-of-the-art, high throughput, twin door vacuum metallizing systems for the automotive industry across the globe. These systems are high production rate vacuum metallization systems designed to deposit coatings onto reflector components made of thermoplastics, thermo sets, and varnished base-coated metals.

### FEATURES:

- High speed rotary, roots and diffusion pumps with cryo-cooler
- Glow discharge substrate pre-clean
- Thermal Evaporation Option:  
Cycle time of < 10 minutes, and Spool size of 960 mm diameter x 1570 mm height
- Sputtering Option:  
Cycle time of < 4 minutes, and Spool size of 710 mm diameter x 1370 mm height
- Plasma polymerization by mid frequency power supply for pre and post coat
- Rotary drive mechanism with ferro fluidic vacuum shaft
- Fully automated operation



# SPECIAL PURPOSE THIN FILM DEPOSITION SYSTEMS

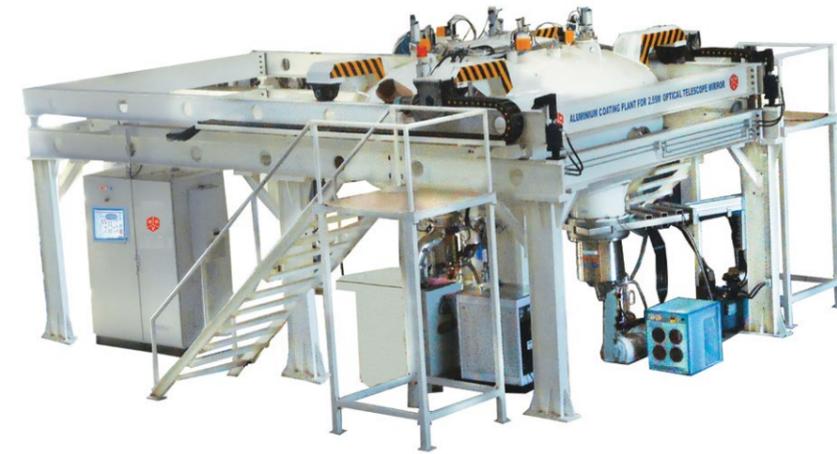


## SPECIAL PURPOSE THIN FILM DEPOSITION SYSTEMS

HHV offers custom designed special-purpose thin film deposition systems for pilot scale research, large area coatings and high throughput industrial applications.



In-line magnetron sputtering system is a model platform for upscaling technologies and pilot scale production



Telescopic mirror coaters for deposition of Aluminium and protected Silver coatings for astronomical applications



Ion Vapor Deposition (IVD) system for plating air-craft components with a protective Aluminum layer



In-line multi chamber PECVD and magnetron systems for industrial scale production of large area coatings



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